BORIDES

Borides in general are us for wear-resistant films and to produce semiconducting films.

Borides are being investigated for use as diffusion barriers in both silicon and III-V device technology in multilevel metallization schemes involving aluminum as a second level.

Titanium boride and zirconium boride films increase the life of cutting tools.

Boride films provide neutron-absorbing layers on nuclear fuel pellets Lanthanum boride films are thermionic conductors

BORIDES						
MATERIAL	FORMULA	STANDARD PURITIES	THEORETICAL DENSITY g/cm3	LISTED MELTING POINT,oC	FABRICATION METHOD	SUGGESTED APPLICATIONS
Chromium boride	Cr2B	99.5	6.57	1890	Hot-pressed	
Chromium boride	CrB	99.5	6.11	2050	Hot-pressed	
Chromium boride	CrB2	99.5	5.60	2150	Hot-pressed	
Chromium boride	CrSB3	99.5	6.12	2000	Hot-pressed	Borides in general are us for wear-resistant films and to produce semiconducting films.
Hafnium boride	HfB2	99.5	11 .1	3250	Hot-pressed	Titanium boride and zirconium boride films increase the life of .cutting tools.

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						Boride films
						provide
						neutron-
						absorbing
						layers on
						nuclear fuel
						pellets
Lanthanum	LaB6	99.5 -99.9	4.68	2100	Hot-pressed	Lanthanum
boride						boride films are
						thermionic
						conductors
						Borides are
						being
						investigated for
						use as diffusion
Molybdenum					Hot-pressed	barriers in both
boride	Mo2B	99.5	9.30			silicon and III-
						V device
				1495		technology in
				1495		multilevel
						metallization
						schemes
						involving
						aluminum as a
						second level
Molybdenum boride	МоВ	99.5	8.77	1083	Hot-pressed	
Malyhdanis	Mo2Bs	99.5	7.48	1063	Hot proceed	
Molybdenum boride	MOZDS	99.5	7.40	1002	Hot-pressed	
Niobium	NbB	99.5	7.60	3727	Hot-pressed	
boride	טטאו	99.5	7.00	3/2/	riot-presseu	
Niobium	NbB2	99.5	7.00		Hot-pressed	
boride	NODE	33.3	7.00	2222	riot pressed	
Tantalum	ТаВ	99.5	14.2	156.2	Hot-pressed	
boride						
Tantalum	TaB2	99.5	12.6		Hot-pressed	
boride				1536		
Titanium	TiB2	99.5	4.53	327.4	Hot-pressed	
boride						
Tungsten	W2B	99.5	17.1	651.0	Hot-pressed	
bori~e						
Tungsten	WB	99.5	16.0	1245	Hot-pressed	
boride	VD	00 5	F 20	2610	Hot process	
Vanadium	VB	99.5	5.28	2610	Hot-pressed	

boride						
Vanadium boride	VB2	99.5	5.10	1453	Hot-pressed	
Zirconium boride	ZrB2	99.5	6.09	2468	Hot-pressed	